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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO
09/196,185	11/20/1998	MYUNG-KEO HUR	6192.0052.AA	8847
75	90 05/28/2002			
1750 TYSONS BOULEVARD SUITE 1800 QI, Z			EXAMINER	
			QI, ZHI	QIANG
MCLEAN, VA	22102		ART UNIT	PAPER NUMBER
			2871	
			DATE MAILED: 05/28/2002	

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)	W				
	09/196,185	HUR ET AL.	•				
Office Action Summary	Examiner	Art Unit					
	Mike Qi	2871					
The MAILING DATE of this communication a Period for Reply	appears on the cover sheet	with the correspondence ac	ddress				
A SHORTENED STATUTORY PERIOD FOR REF THE MAILING DATE OF THIS COMMUNICATION - Extensions of time may be available under the provisions of 37 CFR after SIX (6) MONTHS from the mailing date of this communication If the period for reply specified above is less than thirty (30) days, a r - If NO period for reply is specified above, the maximum statutory peri - Failure to reply within the set or extended period for reply will, by stat - Any reply received by the Office later than three months after the ma earned patent term adjustment. See 37 CFR 1.704(b). Status	N. 1.136(a). In no event, however, may reply within the statutory minimum of od will apply and will expire SIX (6) N tute, cause the application to become	r a reply be timely filed thirty (30) days will be considered time IONTHS from the mailing date of this of ABANDONED (35 U.S.C. § 133).	ely. communication.				
1)⊠ Responsive to communication(s) filed on 0	3 May 2002 .						
2a) This action is FINAL . 2b) ⊠	This action is non-final.						
3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is							
closed in accordance with the practice und Disposition of Claims		C.D. 11, 453 O.G. 213.					
4) Claim(s) 1-21 is/are pending in the application.							
4a) Of the above claim(s) <u>1-3,6-13 and 18-20</u> is/are withdrawn from consideration.							
5) Claim(s) is/are allowed.							
6)⊠ Claim(s) <u>4,5,14-17,21</u> is/are rejected.							
7) Claim(s) is/are objected to.							
8) Claim(s) are subject to restriction and	d/or election requirement.						
Application Papers							
9) The specification is objected to by the Exam							
10) ☐ The drawing(s) filed on is/are: a) ☐ accepted or b) ☐ objected to by the Examiner.							
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).							
11) The proposed drawing correction filed on is: a) approved b) disapproved by the Examiner.							
If approved, corrected drawings are required in reply to this Office action. 12) The oath or declaration is objected to by the Examiner.							
,—	LXammer.						
Priority under 35 U.S.C. §§ 119 and 120	sian priority under 25 U.S.	C & 110(a) (d) or (f)					
13) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).							
a)⊠ All b)□ Some * c)□ None of:	anta hava haan saasiyad						
1. Certified copies of the priority docume		- Annligation No					
2. Certified copies of the priority documents have been received in Application No3. Copies of the certified copies of the priority documents have been received in this National Stage							
 3. Copies of the certified copies of the p application from the International * See the attached detailed Office action for a 	Bureau (PCT Rule 17.2(a)).	ii Stage				
14) Acknowledgment is made of a claim for domestic priority under 35 U.S.C. § 119(e) (to a provisional application).							
a) The translation of the foreign language 15) Acknowledgment is made of a claim for dome	provisional application has	s been received.					
Attachment(s)							
1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO-1449) Paper Note.	5) Notice	ew Summary (PTO-413) Paper N of Informal Patent Application (P					

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DETAILED ACTION

Claim Rejections - 35 USC § 103

- 1. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 2. Claims 4-5 are rejected under 35 U.S.C. 103(a) as being unpatentable over JP 8-254680 in view of US 6,219,125 (Ishikura et al).

Claim 4, JP 8-254680 discloses (col.3, line 42 - col.4, line 17 and Fig.2) that the metal lines (wire) (scanning lines and signal lines) (113) made of molybdenum (Mo), and have a second supplementary layer (115) made of the Mo-alloy and located on the metal wire, and such metal layer has a good chemical resistance and protection to prevent the external influence, and it is especially suitable for protecting the metal layer from chemicals.

The supplementary layer is located either on or under the entire wire, that is to increase the thickness of the metal wire, so as to improve the corrosion resistance, so that decreasing the wire disconnection, and that was at least obvious.

Ishikura discloses (col.3, line 55 - col.4, line 46) that in each metal electrode (3, also is a wire), the adhesive layer (11, also is a wire) preferably comprise a metal Mo or alloy, and a layer of metal nitride would further improve the adhesiveness between the glass substrate and the metal electrodes (3); and a protective layer (13, also is a wire) preferably comprise a metal Mo or

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alloy, and a layer of metal nitride would increase a surface roughness of the metal electrodes (3), thus enhancing an electrical conduction with the transparent electrodes (5).

Therefore, it would have been obvious to those skilled in the art at time the invention was made to arrange a wire layer made of Mo or alloy and a supplementary layer on or under the wire layer using Mo nitride or alloy nitride as claimed in claim 4 for improving the corrosion resistance, improving the adhesiveness and enhancing the electrical conduction with electrodes.

Claim 5, JP 8-254680 discloses (abstract and Fig.2) that the supplementary layer (115) comprising tungsten.

3. Claims 14-17 and 21 are rejected under 35 U.S.C. 103(a) as being unpatentable over Applicant admitted prior art in view of JP 8-254680 and US 6,219,125 (Ishikura et al).

Claims 14 and 21, Applicant admitted prior art (col.1, lines 11-22) indicated that in general, an LCD has:

- a substrate (insulating substrate, e.g., glass);
- a gate wire formed on the substrate;
- a gate insulating layer covering the gate wire;
- a data wire formed on the gate insulating layer;
- a passivation layer formed on the data wire;
- an ITO pixel electrode formed on the passivation layer and connected to the data wire (the drain electrode) through the contact hole.

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Applicant admitted prior art does not expressly disclose the data wire is made of either molybdenum or molybdenum alloy, and a supplementary data wire is located either on or under the entire data wire and made of either molybdenum nitride or molybdenum alloy nitride.

However, JP 8-254680 discloses (col.3, line 42 - col.4, line 17 and Fig.2) that the metal lines (scanning lines and signal lines) made of molybdenum (Mo), and have the second supplementary layer (115) made of the Mo-alloy and located on the metal wire, and such metal layer has a good chemical resistance and protection to prevent the external influence, and it is especially suitable for protecting the metal layer from chemicals.

The supplementary layer is located either on or under the entire wire, that is to increase the thickness of the metal wire, so as to improve the corrosion resistance, so that decreasing the wire disconnection.

Ishikura discloses (col.3, line 55 - col.4, line 46) that in each metal electrode (3, also is a wire), the adhesive layer (11, also is a wire) preferably comprise a metal Mo or alloy, and a layer of metal nitride would further improve the adhesiveness between the glass substrate and the metal electrodes (3); and a protective layer (13, also is a wire) preferably comprise a metal Mo or alloy, and a layer of metal nitride would increase a surface roughness of the metal electrodes (3), thus enhancing an electrical conduction with the transparent electrodes (5).

Therefore, it would have been obvious to those skilled in the art at time the invention was made to arrange a wire layer made of Mo or alloy and a supplementary layer on or under the wire

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layer using Mo nitride or alloy nitride as claimed in claims 14 and 21 for improving the corrosion resistance, improving the adhesiveness and enhancing the electrical conduction with electrodes.

Claims 15-17, JP 8-254680 discloses (abstract; col.3, line 42 - col.4, line 17; Fig.2) that the supplementary layer (115) comprising tungsten, and the supplementary gate layer (115) is located on the gate wire (113) and made of Mo-alloy, and such metal layer has a good chemical resistance and protection to prevent the external influence, and it is especially suitable for protecting the metal layer from chemicals.

Therefore, it would have been obvious to those skilled in the art at time the invention was made to use a supplementary layer as claimed in claims 15-17 for achieving high corrosion resistance and especially for protecting the metal layer from chemicals.

Conclusion

- 4. The prior art made of record and not relied upon is considered pertinent to applicant's disclosure.
- 5. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Mike Qi whose telephone number is (703)308-6213.

Mike Qi May 17, 2002.

TOANTON DEINAMER